



Advances in Plasma and Laser Engineering

Guest Editor:

Dr. Mariusz Jasinski

Institute of Fluid Flow Machinery,
Polish Academy of Sciences,
Gdańsk, Poland

Deadline for manuscript
submissions:

closed (20 November 2023)

Message from the Guest Editor

This Special Issue is intended to provide a description of devices and processes related to the advances in plasma and laser engineering.

Plasma is called the fourth state of matter because its properties differ significantly from those of ordinary gas. Plasma can be determined as a conductive medium generated by the ionization of gases. Therefore, it occurs as a mixture of photons, electrons and ions, but it can also contain neutral atoms and molecules.

A laser is a device that emits electromagnetic radiation in the visible, ultraviolet or infrared range, using the phenomenon of forced emission. Laser radiation is coherent, usually polarized, and has the form of a beam with very little divergence. In a laser, it is easy to obtain radiation with a very small line width, which is equivalent to very high power in a selected narrow spectral region.

Plasma and laser applications include, but are not limited to, the production of new materials and the improvement of the properties of existing materials. The plasma or laser treatment of materials may lead to physico-chemical changes in the structure of their surfaces.





an Open Access Journal by MDPI

Editors-in-Chief

Prof. Dr. Maryam Tabrizian

1. Department of Biomedical Engineering, Faculty of Medicine and Health Sciences, McGill University, Montreal, QC H3A 2B6, Canada

2. Faculty of Dentistry and Oral Health Sciences, McGill University, 3640 Rue University, Montreal, QC H3A 0C7, Canada

Prof. Dr. Yuguang Ma

State Key Laboratory of Luminescent Materials and Devices, South China University of Technology, Guangzhou 510640, China

Message from the Editorial Board

Materials (ISSN 1996-1944) was launched in 2008. The journal covers twenty-five comprehensive topics: biomaterials, energy materials, advanced composites, advanced materials characterization, porous materials, manufacturing processes and systems, advanced nanomaterials and nanotechnology, smart materials, thin films and interfaces, catalytic materials, carbon materials, materials chemistry, materials physics, optics and photonics, corrosion, construction and building materials, materials simulation and design, electronic materials, advanced and functional ceramics and glasses, metals and alloys, soft matter, polymeric materials, quantum materials, mechanics of materials, green materials, general. *Materials* provides a unique opportunity to contribute high quality articles and to take advantage of its large readership.

Author Benefits

Open Access: free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility: indexed within Scopus, SCIE (Web of Science), PubMed, PMC, Ei Compendex, CaPlus / SciFinder, Inspec, Astrophysics Data System, and other databases.

Journal Rank: JCR - Q2 (Metallurgy and Metallurgical Engineering) / CiteScore - Q1 (Condensed Matter Physics)

Contact Us

Materials Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland

Tel: +41 61 683 77 34
www.mdpi.com

mdpi.com/journal/materials
materials@mdpi.com
[X@Materials_Mdpi](https://twitter.com/Materials_Mdpi)